

REMARKS

FIG. 20 is amended to make the figures consistent with the specification. The arrows do not constitute new matter because the specification refers to the arrows and describes that substrates move in the manner shown by the arrows. The specification is amended to correct a typographical error and no new matter is added. The Examiner is invited to telephone Applicant's Attorney at (408) 453-9200, if such would advance the prosecution of this case.

EXPRESS MAIL LABEL NO:

EL 884 818 915 US

Respectfully submitted,



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ATTACHMENT A
(Version with markings to show changes made)

Please amend the paragraph starting on page 15, line 23 as set forth below:

The micromold surface including the photoresist and the substrate can be passivated by allowing the micromold to be exposed to vapors of, e.g., (tridecafluoro-1,1,2,2-tetrahydrooctyl)-1-trichlorosilane (commercially available from Untied Chemical Technologies). A liquid masking composition 146 is then poured over the raised pattern defined by the patterned photoresist. Support 148 is then processed against micromold 140. Uniform pressure is applied such that liquid masking composition [148] 146 is forced out of the area 150 located between the raised portions (i.e., positive features) of the resist pattern and the surface of support 148. Preferably, liquid masking composition 146 is completely squeezed out of the areas 150 corresponding to the positive features of resist 142. The entire assembly 152 remains in this mating relationship until the liquid masking composition has cured. For a heat-curable masking composition, the assembly can be transferred to an oven to cure.

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